



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/780,929

Confirmation Number: 1902

Applicant: Douglas James Tweet *et al.*

Filed: February 17, 2004

Group #: 2818

Examiner: Chuong A. Luu

Docket No: SLA.0735

Customer No: 55376

For: Low Temperature Anneal to Reduce Defects in Hydrogen-Implanted, Relaxed SiGe

MS AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, Virginia 22313-1450

**RESPONSE TO OFFICE ACTION UNDER 37 C.F.R. § 1.111**

**Change of Correspondence Address**

**Introductory Comments**

In response to the Office Action dated July 13, 2005, please amend the above-identified Application as follows:

**Amendment to the Specification** None

**Amendment to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Amendment to the Drawings** None

**Remarks/Arguments** begin on page 7 of this paper.

An **Appendix** is not included.